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## (54) Title of the invention: AUTOMATED SHOE CLEANING AND POLISHING APPARATUS

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(57) Abstract:

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The present invention relates to an automated shoe cleaning and polishing apparatus (100) to clean and polish the shoe while wearing the shoe. The apparatus (100) includes a housing assembly (102) having a first cavity (104) and a second cavity (122). One or more sensors (114) attached to the housing assembly (102) to detect the received shoe. The first cavity (102) is configured to clean sole and all sides of the received shoe by a cleaning assembly (106). Additionally, the second cavity (122) configured to polish the received shoe with a polishing assembly (124), where the polishing assembly (124) includes a reservoir (126) to store shoe polish, and a sprayer (128) to spray the polish on the received shoe.

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